



A Widely-Applicable Gold Substrate for the Study of Ultrathin Overlayers

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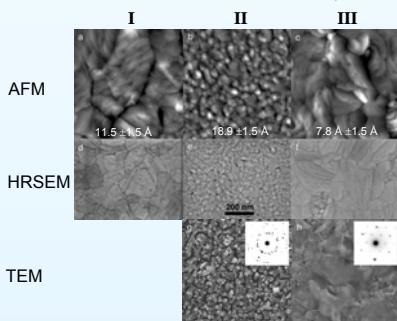
In this work we show that 15-nm-thick gold films evaporated on silanized glass and annealed are semi-transparent, electrically conducting, and morphologically well-defined, showing a smooth, {111} textured surface. Such Au films provide a high-quality, widely-applicable and relatively inexpensive platform for ultrathin overlayers, enabling characterization by a wide spectrum of experimental methods, applied to the same substrate. The exceptional qualities and analytical capabilities of such substrates are demonstrated with several different systems: (i) Cu underpotential deposition (upd); (ii) alkanethiol self-assembly; (iii) formation of gold nanoparticle layers; (iv) binding of the chromophore protoporphyrin IX (PPIX) to a monolayer of 11-mercaptopundecanoic acid (MUA). In the latter case it is shown that the use of Cu^{2+} ions for binding between the carboxylate groups of PPIX and MUA promotes better organization of the porphyrin layer.

Morphology and surface structure of thin, continuous, transparent gold substrates

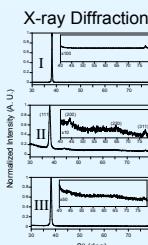
1. a-c: Non-contact AFM (a-c) of gold substrates I, II, III, respectively (z-scale: 50 Å (I), 90 Å (II), 35 Å (III)). Roughness values are shown on bottom of images.

d-f: High-resolution SEM (HRSEM) of gold substrates I, II, III, respectively.

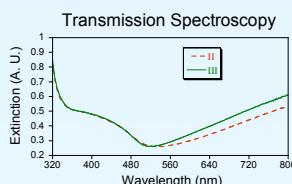
g-h: TEM images and selected-area (80 nm aperture) diffraction patterns (insets) of substrates II and III, respectively.



2. X-ray diffraction (0-20) shows annealed substrates I and III are more oriented and {111} textured:



3. Transmission UV-vis spectroscopy of unannealed (II) and annealed (III) substrates shows slight increases in extinction following annealing:



4. Electrochemical characterization.

Left: Cyclic voltammetry of Au substrates I, II, III in 0.1 M H_2SO_4 showing the Au oxide formation/stripping waves. Scan rate: 0.1 V/s.

Right: Cu underpotential deposition (upd) on Au substrates I, II, III in 1.0 mM $\text{CuSO}_4 + 0.1 \text{ M H}_2\text{SO}_4$. Scan rate: 0.02 V/s.

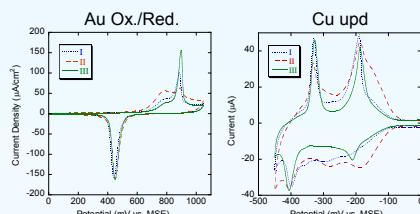
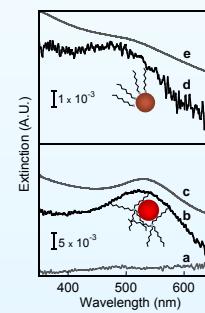


Table: Calculated roughness of substrates I-III

Substrate	Q_{oxide} ($\mu\text{C}/\text{cm}^2$, $\pm 3.5\%$)	Roughness ($\pm 3.5\%$)
I	533.3	1.33
II	749.0	1.87
III	558.5	1.39

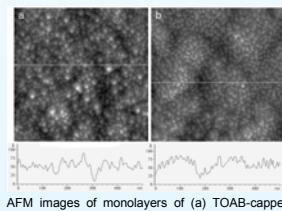
Versatility of the transparent gold substrates in characterization of ultrathin overlayers

1. AFM, ellipsometry, contact angles, UV-vis transmission spectroscopy of a single layer of Gold nanoparticles (NPs) on annealed transparent substrates (III)



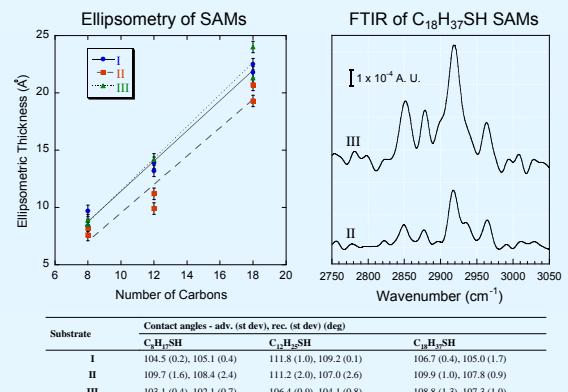
Adsorbate	NPs on dithiol SAM	
	Ellipsometry ^a -ΔA (deg)	CA (deg) adv(st dev), rec(st dev)
TOAB-capped NPs	8.1±0.3	86(3), 36(4)
Octanethiol-capped NPs	3.0±0.1	105(2), 96(4)

^aFor the SAM of 1,10-decanedithiol, -ΔD = 1.1° ± 0.1°.

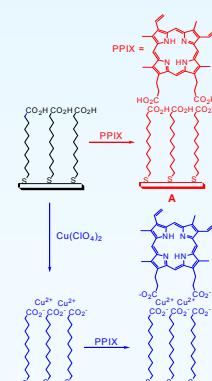


AFM images of monolayers of (a) TOAB-capped and (b) octanethiol-capped NPs bound onto 1,10-decanedithiol SAMs (500x500 nm²).

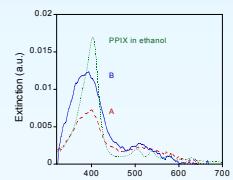
2. Alkanethiol SAMs characterization by ellipsometry, water contact angles, and RA-FTIR spectroscopy



3. Protoporphyrin IX (PPIX) binding to free (A) and Cu^{2+} -bound (B) carboxylic acid SAMs, monitored by transmission UV-vis spectroscopy, ellipsometry and contact angles.



- PPIX forms well-packed monolayers on Cu^{2+} -bound carboxylic SAMs than on free carboxylic acid SAMs.



Route (Substrate)	MUA		Cu^{2+}		PPIX	
	Thickness (±1 Å)	CA (deg) adv (st dev), rec (st dev)	Thickness (±1 Å)	CA (deg) adv (st dev), rec (st dev)	Thickness (±1 Å)	CA (deg) adv (st dev), rec (st dev)
A (I)	16.6	18.2 (1.5), -			29.7	50.0 (7.0), 28.2 (2.9)
A (II)	15.4	19.3 (2.5), -			25.1	47.4 (9.9), 22.7 (2.9)
A (III)	16.3	21.7 (2.4), -			30.8	52.9 (4.7), 23.1 (3.0)
B (I)	18.2	31.4 (4.6), -	18.7	35.0 (1.5), 32.0 (4.8)	36.0	76.1 (1.0), 66.2 (3.7)
B (II)	14.5	17.0 (2.5), -	18.4	31.6 (3.6), 25.0 (3.6)	34.1	75.9 (0.9), 72.2 (2.0)
B (III)	17.2	21.0 (1.8), -	19.5	35.4 (2.9), 26.7 (1.9)	34.1	78.6 (0.5), 73.5 (2.0)

Conclusions

- Semi-transparent continuous, 15-nm-thick Au films are stable, morphologically well-defined and highly versatile substrates for the preparation and study of SAMs and other kinds of ultrathin overlayers on Au.
- This enables the use of a wide spectrum of characterization methods, applied to the same substrate, including AFM, XRD, TEM, SEM, XPS, electrochemical methods, CA measurements, ellipsometry, transmission spectroscopy, and RA-FTIR spectroscopy.
- These substrates exhibit a morphology similar to that of thick (≥ 100 nm) annealed Au films, showing large, flat domains, a strong {111} texture and a low roughness factor.